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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/620,072	07/15/2003	Chee Wei Wong	MIT.9923	7118
7	590 09/13/2004		EXAMINER	
Samuels, Gauthier & Stevens LLP			KANG, JULIANA K	
Suite 3300 225 Franklin St	treet		ART UNIT	PAPER NUMBER
Boston, MA 021	2110		2874	<del></del>
			DATE MAILED: 09/13/200	4

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	•
	10/620,072	WONG ET AL.	•
Office Action Summary	Examiner	Art Unit	
	Juliana K. Kang	2874	
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet wi	th the correspondence address -	<b></b>
A SHORTENED STATUTORY PERIOD FOR REI THE MAILING DATE OF THIS COMMUNICATIO  - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a  - If NO period for reply is specified above, the maximum statutory per  - Failure to reply within the set or extended period for reply will, by sta Any reply received by the Office later than three months after the may earned patent term adjustment. See 37 CFR 1.704(b).	N. R 1.136(a). In no event, however, may a reply within the statutory minimum of third iod will apply and will expire SIX (6) MON atute, cause the application to become AB	reply be timely filed by (30) days will be considered timely. ITHS from the mailing date of this communicated BANDONED (35 U.S.C. § 133).	ation.
Status			
1) Responsive to communication(s) filed on	·		
	his action is non-final.		
3) Since this application is in condition for allow		ers, prosecution as to the merits	s is
closed in accordance with the practice unde	er <i>Ex par</i> te Quayle, 1935 C.D	. 11, 453 O.G. 213.	
Disposition of Claims			
4)⊠ Claim(s) <u>1-22</u> is/are pending in the applicati	ion.		
4a) Of the above claim(s) is/are without	drawn from consideration.		
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>1-22</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and	d/or election requirement.		
Application Papers			
9) The specification is objected to by the Exam	iner.		
10)⊠ The drawing(s) filed on 05 July 2003 is/are:	a) accepted or b) ⊠object	ted to by the Examiner.	
Applicant may not request that any objection to t	the drawing(s) be held in abeyar	ice. See 37 CFR 1.85(a).	
Replacement drawing sheet(s) including the corr	rection is required if the drawing	(s) is objected to. See 37 CFR 1.12	?1(d).
11)☐ The oath or declaration is objected to by the	Examiner. Note the attached	d Office Action or form PTO-152	2.
Priority under 35 U.S.C. § 119			
12) ☐ Acknowledgment is made of a claim for fore a) ☐ All b) ☐ Some * c) ☐ None of:		; 119(a)-(d) or (f).	
1. Certified copies of the priority docume			
2. Certified copies of the priority docume		•••	
3. Copies of the certified copies of the p	•	received in this National Stage	
application from the International Bure * See the attached detailed Office action for a l	, , , , , , , , , , , , , , , , , , , ,	received	
	iot of the defailed deplot flot		
Attachment(s)			
1) X Notice of References Cited (PTO-892)		Summary (PTO-413)	
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	_	s)/Mail Date nformal Patent Application (PTO-152)	
<ol> <li>Information Disclosure Statement(s) (PTO-1449 or PTO/SB/ Paper No(s)/Mail Date <u>2/9/04</u>.</li> </ol>	6) Other:		

#### **DETAILED ACTION**

### Inventorship

1. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(f) or (g) prior art under 35 U.S.C. 103(a).

## **Drawings**

2. The drawings are objected to because Figures 1-3 are not legible. Corrected drawing sheets in compliance with 37 CFR 1.121(d) are required in reply to the Office action to avoid abandonment of the application. Any amended replacement drawing sheet should include all of the figures appearing on the immediate prior version of the sheet, even if only one figure is being amended. The figure or figure number of an amended drawing should not be labeled as "amended." If a drawing figure is to be canceled, the appropriate figure must be removed from the replacement sheet, and where necessary, the remaining figures must be renumbered and appropriate changes made to the brief description of the several views of the drawings for consistency. Additional replacement sheets may be necessary to show the renumbering of the

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remaining figures. The replacement sheet(s) should be labeled "Replacement Sheet" in the page header (as per 37 CFR 1.84(c)) so as not to obstruct any portion of the drawing figures. If the changes are not accepted by the examiner, the applicant will be notified and informed of any required corrective action in the next Office action. The objection to the drawings will not be held in abeyance.

### Specification

3. Applicant's assistance is requested to correct any errors that may be noticed in the application.

### Claim Objections

4. Claims 19-22 are objected to because of the following informalities: Claims 19-22 recites "the method of claim" in the beginning of each claim. It appears that claims have incorrect dependencies. Because the method claims 12-18 are exactly parallel to the preceding apparatus claims, the Examiner will interpret the claims 19, 20 and 22 as dependent claims of claim 18 and claim 21 as dependent claim of claim 20 for the examination purpose. Appropriate correction is required.

#### Claim Rejections - 35 USC § 102

5. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.

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6. Claims 1, 3-5, 7, 9-12, 14-16, 18, and 20-22 are rejected under 35 U.S.C. 102(a) as being anticipated by Matsuura et al (WO 02/10843 A2).

Matsuura et al disclose a photonic bandgap microcavity comprising a membrane structure (support) that can experience strain (see page 7 lines 2-9); and a photonic bandgap waveguide element formed on said membrane structure having a defect so that when said membrane structure is strained, said photonic bandgap waveguide element is tuned to a selective amount (see page 2 lines 27-30, page 6 lines 16-22, page 7 lines 22-25 and page 9 lines 20-24). Matsuura et al further disclose that the invention is applied to 1-dimentional, 2-dimentional and 3-dimentional photonic crystals (see page 8 lines 26-30). Matsuura et al further disclose using a bottom electrode and a top electrode to deform the membrane structure to tune the photonic bandgap waveguide using micro-actuators including a piezoelectric actuator (see page 13 lines 27-30, page 15 lines 22-33 and page 19 lines 1-9 and line 15-17).

Please note, regarding the method claims above, that method claims parallel article claims exactly without the introduction of any particular manufacturing methods, sot that it is proper to examiner the article and method claims together.

#### Claim Rejections - 35 USC § 103

7. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

<sup>(</sup>a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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8. Claims 2 and 13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Matsuura et al and further in view of Caracci et al (U.S. Patent 6,445,838 B1).

Matsuura et al disclose using silicon-based substrates that can be physically deformed due to piezoelectric response but does not explicitly teach SiO<sub>2</sub> layer. Silica is well known material used in the art and furthermore Caracci et al that silica is expandable in response to the stimulus of heat or a piezoelectric material which is expandable in response to the stimulus of voltage. Thus, it would have been obvious to one having ordinary skill in the art at the time the invention was made to a use silicon based substrate such as SiO<sub>2</sub> in Matsuura et al as taught by Caracci et al to tune the waveguide element.

9. Claims 6, 8,17 and 19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Matsuura et al.

Regarding claims 6, 8, 17 and 19, as described above Matsuura et al disclose the claimed invention except the claimed strain approximately 1% or strain on the membrane between 0.2 and 0.3%. Matsuura et al tuning of photonic crystal by stressing the membrane permits precise control of light traveling thought the photonic bandgap waveguide (see page 3 lines 24-27, page 6 lines 1-8, and page 8 lines 26-30). Since Matsuura et al provide the same claimed structure and also teaches tuning of the photonic crystal precisely, it would have been obvious to one having ordinary skill in the art at the time the invention was made to tune the device with any desired tuning including the claimed tuning of approximately 1% or to introduce strain on the

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membrane between 0.2% and 0.3%, since it has been held that discovering an optimum value of a result effective variable and discovering the optimum or workable ranges involves only routine skill in the art.

Please note, regarding the method claims above, that method claims parallel article claims exactly without the introduction of any particular manufacturing methods, sot that it is proper to examiner the article and method claims together.

#### Conclusion

- 10. The prior art documents submitted by applicant have been considered and made of record (note the attached copy of form PTO-1449).
- 11. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Juliana K. Kang whose telephone number is (571) 272-2348. The examiner can normally be reached on Mon. & Fri. 10:00-6:00 and Tue. & Thur. 10:00-3:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Rod Bovernick can be reached on (571) 272-2344. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Juliana Kang

September 9, 2004